

Thin- film heating element

The present invention relates to a film heating element comprising an aluminum substrate, an electrically insulating layer, and an electrically resistive layer, as well as to an electrical domestic appliance comprising such a heating element.

In general, a film heating element consists of two functional layers applied on
5 a substrate, namely, an electrically insulating layer and an electrically resistive layer. Heat is generated by flow of an electrical current through the resistive layer. The function of the insulating layer is to isolate the heat-generating resistive layer from the metal substrate, which may be directly accessible from the outside.

The resistive layer can be electrically contacted with a supply voltage via
10 highly conductive tracks. These conductive tracks are generally patterned.

Flat-film heating elements can be roughly divided into two main categories, namely thick-film heating elements and thin-film heating elements.

The distinction between these two categories concerns the thickness of the resistive layer. In thick-film heating elements, the resistive layer has a thickness exceeding 2
15 μm . These films are mainly prepared by means of screen-printing techniques. In thin-film heating elements, the resistive layer has a thickness smaller than 2 μm .

These films are mainly prepared by means of evaporation techniques or via pyrolysis of precursor solutions.

20

A thin-film heating element is known from U.S. Pat. No. 4,889,974. Said patent discloses a thin-film heating element prepared by means of a wet-chemical process. This thin-film heating element consists of a resistive layer applied directly on an isolating substrate such as a hard glass substrate, a quartz glass substrate, or a ceramic substrate. An
25 SnO_2 film doped with acceptor- and donor-forming elements is described as a resistive layer. The films are manufactured from a solution by means of a spray pyrolysis process followed by curing at 600°C.

A number of patents disclose thin-film heaters on electrically conductive substrates, e.g. steel. An insulating layer (e.g. polymer, enamel, etc.) is applied on these

electrically conductive substrates in order to insulate the resistive layer from the substrate. A thin resistive layer is applied on top of these insulating layers.

However, until recently no thin-film heaters on aluminum or aluminum alloy substrates have been reported. Aluminum and its alloys have a relatively high coefficient of expansion (22-26 ppm/K) compared to the insulating layers used for steel substrates which are in most cases enamel-based insulators. Insulating layers commonly used for steel substrates cannot be used for aluminum (alloy) substrates. Mismatched thermal expansion coefficients result in cracking of the film when the heating element is exposed to temperature cycles. Furthermore, in order to apply these insulators, the precursors are applied on a suitable substrate, after which the precursor has to be cured at high temperatures above 650 °C in order to obtain a suitable insulating layer. These high curing temperatures exceed or are near to the melting temperature of aluminum (660 °C) and its alloys. Therefore, these materials are not suitable as electrically insulating layers for aluminum substrates

EP-A-0891118 discloses a thin-film heater in which a ceramic layer is used as an insulating layer for an aluminum substrate. However, the difference in expansion coefficients between the ceramic insulator layer and the aluminum is bridged in this patent in that the heating element is first provided on a stainless steel plate, after which the stainless steel plate is glued to an aluminum plate with e.g. a silicone-based glue.

20

It is an object of the present invention to provide a heating element of the preamble suitable for an aluminum substrate in which no cracks are formed when the element is subjected to temperature cycles. Where the term aluminum is used, it comprises aluminum, anodized aluminum, and alloys of aluminum. Furthermore, the present invention aims to provide an electrical domestic appliance including such a heating element, as well as to a method of manufacturing said heating element.

These and other objects of the invention are achieved by a film heating element, at least comprising an aluminum substrate, an electrically insulating layer which is based on a sol-gel precursor, and an electrically resistive layer with a thickness smaller than 2 µm.

A heating element according to the invention has several advantages. First of all no crack formation is observed when the heating element is exposed to temperature cycles between 20 and 300 °C.

Furthermore, the heating element is suitable for high-power applications, with a power density of 20 W/cm^2 or higher at a substrate temperature of 300°C .

The film heating element according to the invention comprises an electrically resistive layer with a thickness smaller than $2 \mu\text{m}$. This resistive layer preferably comprises a metal, a metal oxide, or a doped metal oxide. A suitable metal is aluminum. Suitable metal
5 oxides are tin oxide, indium-tin oxide (ITO). Suitable doped metal oxides are fluoriné or aluminum-doped zinc oxide, or tin oxides doped with fluorine or antimony.

It was surprisingly found that, although e.g. ITO has a thermal expansion coefficient of about 4 ppm/K compared to about 23 ppm/K for aluminum, no crack formation
10 was observed when the heating element of the invention was exposed to repeated temperature cycles between 20 and 300°C .

The resistive layer may be applied to the insulating layer by means of (atmospheric) chemical vapor deposition ((A) CVD), physical vapor deposition (PVD), magnetron sputtering, thermal spraying, or wet-chemical techniques.

The resistive layer preferably consists of an inorganic material. Suitable
15 inorganic materials are a metal, a metal oxide, and a doped metal oxide. A suitable metal is aluminum. Suitable metal oxides are tin oxide, indium-tin oxide (ITO). Suitable doped metal oxides are fluoriné or aluminum-doped zinc oxide, or tin oxides doped with fluorine or antimony. Resistive layers of an inorganic material do not risk the formation of a carbonized
20 conductive track.

The heating element of the invention further comprises an electrically insulating layer that is based on a sol-gel precursor.

The application of an electrically insulating layer based on a sol-gel precursor provides several advantages. First of all, the sol-gel precursor based layer shows excellent
25 electrical insulating properties. The carbon content of a sol-gel precursor based material is sufficiently low to prevent the formation of a carbonized conductive track in case of failure of the heating, thereby providing a safe heating element. Also, sol-gel materials have a high thermal conductivity which is in the order of magnitude of $0.1\text{-}2 \text{ W/m}^\circ\text{K}$. Furthermore, sol-gel precursors can be processed at temperatures below 400°C , which makes this material
30 suitable to be applied directly to aluminum substrates. Due to the lower curing temperature of the hybrid sol-gel precursor, the mechanical properties of the aluminum will be maintained. The sol-gel precursor is preferably applied on an anodized aluminum substrate, to ensure good adhesion of the sol-gel layer.

Although the sol-gel insulating layer is especially suitable for application on aluminum substrates, other substrates which are conventionally used for heating elements and which are compatible with the final utility may also be used. Said substrates may include, for example, stainless steel, enameled steel, or copper. The substrate may be in the form of a flat plate, a tube, or any other configuration that is compatible with the final utility.

Preferably, the sol-gel precursor is a hybrid sol-gel precursor comprising an organosilane compound.

A preferred silane is a silane that forms a hybrid sol-gel precursor. A hybrid sol-gel precursor comprising an organosilane compound is understood to be a compound comprising silicon, which is bonded to at least one non-hydrolysable organic group and 2 or 3 hydrolyzable organic groups.

In an advantageous embodiment, the sol-gel material may also comprise silica particles, in particular colloidal silica particles.

In particular, the hybrid sol-gel precursor comprises an organosilane compound from the group of alkyl-alkoxysilanes.

Preferably, the hybrid sol-gel precursor comprises methyl-trimethoxysilane (MTMS) and/or methyl-triethoxysilane (MTES). An advantage of the heating element of the invention based on the hybrid sol-gel system is a relatively high power density, and optimized thermal expansion coefficient values for aluminum.

Hybrid sol-gel precursors such as MTMS and MTES are known to have an excellent temperature stability up to at least 450 °C. Moreover, MTMS has been shown to prevent silver oxidation and subsequent migration effectively. The carbon content of these materials is still low, so carbonized conductive tracks across the insulating layer will not form after failure, making a safe heating element. The maximum layer thickness of coatings made from hybrid precursors is relatively high, compared to the maximum layer thickness of coatings made from non-hybrid sol-gel materials. Therefore, the layers can be deposited in one or at most two steps without intermediate curing.

Advantageously, the electrically insulating layer comprises non-conductive particles.

A fraction of said non-conductive particles preferably has a flake-like shape and a longest dimension of 2-500 µm, preferably from 2 to 150 µm, and more preferably from 5 to 60 µm. These flake-like non-conductive particles are based on oxides such as, for example, mica or clay, and/or surface-modified mica or clay particles with a coating of titanium dioxide, aluminum oxide, and/or silicon dioxide. The flake-like material content in

the insulating layer should be less than 20 vol %, preferably less than 15 vol %, and more preferably less than 4-10 vol %. An advantage of such anisotropic particles is that their presence prevents the formation of cracks in the electrically insulating layer after frequent heating up and cooling down of the element.

5 In the preferred embodiment, the non-conductive particles are present in colloidal form. Examples thereof are oxides like aluminum oxide and silicon dioxide. Preferably, the aluminum oxide content in the insulating layer should be less than 40 vol %, preferably less than 20 vol %, and more preferably 10-15 vol %. As for the silicon dioxide content in the insulating layer, it should advantageously be less than 50 vol %, preferably less
10 than 35 vol %, and more preferably less than 15-25 vol %.

If an insulating layer is based on MTMS or MTES filled with particles, including anisotropic particles, a layer thickness of just 50 μm can withstand 5000V. This relatively small layer thickness allows the temperature difference across the thickness of the resistive layer to be fairly low, which allows for a much lower temperature of the heating
15 resistive layer for obtaining a certain temperature of the aluminum substrate. For this reason said thin layers are advantageously used. The layers may be applied by any wet-chemical application method, preferably spray coating or screen-printing followed by a curing step.

The heating element according to the invention may further comprise an electrically conductive layer. The electrically conductive layer in the heating element of the
20 invention comprises a layer with a relatively low ohmic resistance with respect to the electrically resistive layer and acts as a contacting layer between the heat-generating resistive layer and an external power source.

The conductive layer may consist of a metal, e.g. aluminum, or of a hybrid material such as PI/Ag, or a sol-gel/Ag paste. The conductive layer may be applied by means
25 of (A)CDV, PVD, magnetron sputtering, thermal spraying, and wet-chemical or screen printing techniques.

The preferred technique for applying the conductive tracks is screen printing. Commercially available metal powders may be used for the conductive track. It is preferred to use silver or silver alloy particles

30 Other metals and semiconductors may be used in making conductive layers for the application, provided they have a sufficiently high temperature stability in the sol-gel matrix. The use of MTMS or MTES precursors reduces the rate of oxidation of silver and graphite particles at high temperatures of the heating element. In that respect it has been

noted that graphite in an MTES derived matrix has shown a stability of more than 600 hours at 320°C.

To make the formulations screen-printable, a cellulose derivative may be added to the particle-containing, hydrolyzed MTMS or MTES solution. Hydroxyl-propyl-methyl cellulose is preferably used as the cellulose material. Finally, a solvent with a high boiling point is added to prevent drying of the ink and subsequent clogging of the screen. Butoxyethanol was found to be a suitable choice, but other polar solvents, preferably alcohols, are also found appropriate.

Optionally, the element may be covered with a protective topcoat layer. This topcoat layer mainly serves as a protective layer against mechanical damage during handling of the element. With the use of, for instance, silica-filled hybrid sol-gel solution, for example based on MTMS, a screen-printable formulation can be easily made. The applied topcoat layer may be co-cured with the conductive layer and the resistive layer.

The invention further relates to an electrical domestic appliance comprising at least the heating element of the invention. Heating elements of the present invention are very suitable for heating elements in laundry irons, especially for the controlled formation of steam, for which high power densities are required. However, the heating elements are also very suitable for other domestic applications like hair dryers, hair stylers, steamers and steam cleaners, garment cleaners, heated ironing boards, facial steamers, kettles, pressurized boilers for system irons and cleaners, coffee makers, deep-fat fryers, rice cookers, sterilizers, hot plates, hot-pots, grills, space heaters, waffle irons, toasters, ovens, or water flow heaters.

The invention also relates to a method of manufacturing a heating element according to the invention, at least comprising the steps of: providing an aluminum substrate; applying an electrically insulating layer on said substrate; and applying a resistive layer on top of the electrically insulating layer, characterized in that the electrically insulating layer is obtained by means of a sol-gel process and the resistive layer has a thickness smaller than 2 μm . In particular, the sol-gel process at least comprises the step of mixing an organosilane compound with water.

The invention will be further elucidated in the following manufacturing example.

Example

A 200 nm thin layer (72*64 mm) of ITO (90 wt % In_2O_3 , 10 wt% SnO_2 purity more than 99.99%) was applied by means of DC magnetron sputtering in an argon/oxygen

atmosphere with a Leybold Z650 Batch system (starting initial pressure below 4.0×10^{-6} mBar, deposition speed 20 nm/min) onto a 50 μm thick insulating layer based on a sol-gel precursor on an aluminum substrate. Conductive layers (PI/Ag-based paste, PM437 by Acheson) of about 10 μm thick were applied by means of screen printing. After drying for 30
5 minutes at 80 °C, the conductive layer was cured for 30 minutes at 375 °C in an air atmosphere. The resulting resistance is about 36 Ω with a surface resistance of 0.27 Ω/\square (for a 25.5 μm thick layer)

After application of a voltage, the resulting heating element operates with a power density of 20 W/cm² at a substrate temperature setting of 240 °C.